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An Inverted FL Antenna for Dual-Frequency Operation

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Abstract—An inverted FL antenna (InvFLA) is analyzed to obtain dual-frequency operation at 2.45 and 5.2 GHz (wireless LAN system frequencies). The InvFLA is composed of inverted FL elements, a parasitic element, and a ground plate, where these lie in the same plane, i.e., the structure is a card-type structure having a co-planar ground plate. The antenna height above the ground plate is very small: 5.5 mm =0.045 wavelength at 2.45 GHz. The analysis shows that the InvFLA has a 4.1% bandwidth around 2.45 GHz and a 31.8% bandwidth around 5.2 GHz, both for a VSWR =2 criterion. The gain is calculated to be 0.9 dBi at 2.45 GHz and 1.7 dBi at 5.2 GHz, with a small gain variation in each of the VSWR bands.

 $\label{local-continuity} \emph{Index Terms} \mbox{--} \mbox{Card-type antenna, dual-frequency operation, finite-difference time-domain (FDTD) analysis, inverted F, inverted L.}$

I. INTRODUCTION

HE increasing demand for wireless communications has been accelerating development of new antennas that operate in the required frequency bands [1]–[5]. The dual-frequency antenna is one of these new antennas, and so far numerous efforts have been made in this area [6]–[8]. For example, Wong has investigated microstrip patches for dual-frequency operation and summarized them in [9].

This paper presents an antenna that responds to the above-mentioned trend: an inverted FL antenna (InvFLA) for dual-frequency operation. The InvFLA is made of a thin conducting film, having a flat structure, as shown in Fig. 1(b), where both the radiation element (inverted F and L strip lines) in the positive y space and the ground plate (GP) in the negative y space lie in the same plane (x-y plane). In other words, the InvFLA has a co-planar ground plate, forming a card-type antenna structure.

The card-type InvFLA structure differs from the layered microstrip antenna structure for dual-frequency operation in [9], where the ground plate backs a radiation element (patch element), i.e., the patch is parallel to the ground plate. It is emphasized that the card-type structure facilitates the use of the InvFLA in PC card devices for personal computers or inside mobile phone handsets.

After a brief summary of the analysis methods, which are based on the finite-difference time-domain method (FDTDM) [10], this paper investigates an InvFLA for realizing dual-frequency operation at 2.45 and 5.2 GHz (frequencies used for wireless LAN communications). Note that the final structural parameters for the InvFLA are obtained through a step-by-step

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 $\begin{array}{c|c} H_L & H_F \\ \hline \\ L_{FD} & L'_F & L_P \\ \hline \\ G.P. & (L_x \times L_y) \\ \hline \\ H_L & H_F \\ \hline \\ H_P & X \\ \hline \\ L_{FD} & L_F & L_P \\ \hline \\ G.P. & (L_x \times L_y) \\ \hline \\ L_X & (b) \\ \hline \end{array}$

Fig. 1. Antenna structures. (a) A compound of inverted L and F elements (referred to as a *compounded LF*) with a parasitic L element above a co-planar ground plate (GP). (b) A compounded LF with a modified parasitic L element above a co-planar ground plate, referred to as the inverted FL antenna (InvFLA). The ground plate size in (a) is the same as that in (b): $L_x \times L_y = 30 \ \mathrm{mm} \times 25.5 \ \mathrm{mm}$.

investigation of the following structures: 1) an inverted L element; 2) an inverted F element; 3) a compound of the inverted L and F elements, referred to as a compounded LF; 4) the compounded LF with a parasitic inverted L element; and 5) the compounded LF with a modified parasitic inverted L element. Also, note that the design process presented in this paper is not necessarily restricted to the specific frequencies 2.45 and 5.2 GHz. It is possible to apply the same design technique to other dual-frequency antenna designs.

For confirmation of the FDTDM results (obtained using the FDTDM computer programs developed by the authors), experimental results are presented. A good agreement between the FDTDM results and the experimental results is found.

II. CONFIGURATION

Fig. 1(a) shows a step involved in reaching the antenna structure of Fig. 1(b). The radiation element in Fig. 1(a) is a compound of three sub-elements: an inverted L element (see inset (I) of Fig. 2, where elements α - β - γ and α' - β' - γ' are collectively referred to as the "inverted L element"), an inverted F element (see inset (II) of Fig. 2), and a parasitic inverted L element (simply referred to as a *parasitic L element*).

Fig. 1(b) is a modified version of the structure in Fig. 1(a), where a small protrusion of area $A_x \times A_y$ is added to the parasitic L element in Fig. 1(a). The structure of Fig. 1(b) is based on the inverted L and F elements, and hence it is referred to as the *inverted FL antenna* (InvFLA). It is emphasized that the InvFLA is made of a thin conducting film, where the ground plate (GP) is a co-planar ground plate, i.e., the ground plate and the radiation element lie in the same plane (x-y) plane, forming a card-type structure.

The heights of the radiation sub-elements $(H_L, H_F, \text{ and } H_P)$ and the ground plate size $(L_x \times L_y)$ in Fig. 1(b) are the same as those in Fig. 1(a). However, the horizontal lengths L_L and L_F in Fig. 1(b) are slightly different from L_L' and L_F' in Fig. 1(a), respectively, as will be revealed later.

The InvFLA is excited at terminals P and Q, where the distance between P and Q is fixed to be 0.5 mm. The distance from the left side edge of the ground plate to terminal P is denoted as $L_{\rm FD}$. For the experimental work, the InvFLA is excited through a 50-ohm coaxial line without a balun circuit, where the inner conductor of the coaxial line is connected to point Q and the outer conductor is soldered to the ground plate. To facilitate a PC card implementation, a thin coaxial line can be used (a coaxial line whose outer diameter is 0.8 mm is commercially available).

The ground plate size and the strip line width of the radiation element are fixed to be $L_x \times L_y = 30 \text{ mm} \times 25.5 \text{ mm}$ and w = 1 mm, respectively, throughout this paper. There are nine structural parameters to be determined: the heights (H_L, H_F, H_P) , the strip line lengths (L_L, L_F, L_P) , the protrusion size (A_x, A_y) , and the feed point location $L_{\rm FD}$. In this paper, the heights (H_L, H_F, H_P) are pre-selected to be small with respect to the wavelengths at 2.45 and 5.2 GHz: $(H_L, H_F, H_P) = (4.5 \text{ mm}, 2.5 \text{ mm}, 2.5 \text{ mm})$. The remaining structural parameters (L_L, L_F, L_P) , (A_x, A_y) and $L_{\rm FD}$ are to be determined for operation at 2.45 and 5.2 GHz.

III. ANALYSIS AND DISCUSSION

Analysis is performed using the finite-difference time-domain method (FDTDM). For this, Yee's algorithm based on rectangular cells [10] is adopted, where the analysis space is terminated using Liao's second order absorbing boundary condition [11]. The antenna excitation is modeled by a delta-gap voltage source $V_{\rm in}(t)$, which is defined by a sine function modulated by a Gaussian function: $V_{\rm in}(t) = V_{\rm gauss}(t) \sin \omega t$, where $V_{\rm gauss}(t) = \exp\{-(t-T)/KT\}^2$, with K=0.29 and $T=0.646/f_{\rm 3dB}$. Note that $f_{\rm 3dB}$ is the frequency at which the power spectrum (|Fourier transform of $V_{\rm gauss}(t)|^2$) drops 3 dB from its maximum value. The electric field at a far-field point, $E_{\rm Far}$ (composed of E_{θ} and E_{ϕ}), is calculated on the basis of the equivalence principle [12].

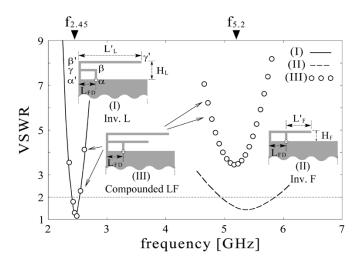


Fig. 2. VSWRs of three structures. The structural parameters for an inverted L element (I) are $(H_L, \ L_L') = (4.5 \ \mathrm{mm}, \ 27.5 \ \mathrm{mm})$ and $L_{\mathrm{FD}} = 7.5 \ \mathrm{mm}$, and those for an inverted F element (II) are $(H_F, \ L_F') = (2.5 \ \mathrm{mm}, \ 11 \ \mathrm{mm})$ and $L_{\mathrm{FD}} = 7.5 \ \mathrm{mm}$. A compounded LF (III) has the same structural parameters used for the sub- elements (I) and (II). The ground plate sizes in structures (I), (II), and (III) are the same: $L_x \times L_y = 30 \ \mathrm{mm} \times 25.5 \ \mathrm{mm}$.

The InvFLA is intended for installation in *mobile* equipment. In such a case, polarization purity (low cross polarization) is not required; however, an appropriate VSWR frequency response must be realized. The structural parameters for the InvFLA, Fig. 1(b), are obtained through the five steps described below, where the first three steps are rough adjustments and the fourth and fifth steps are devoted to a fine-tuning of the design.

For the first step, the inverted L element [see inset (I) of Fig. 2] is analyzed for a height of $H_L=4.5 \mathrm{mm}=0.0368 \lambda_{2.45}$, pre-selected in Section II, where $\lambda_{2.45}$ is the wavelength at 2.45 GHz ($\equiv f_{2.45}$). To obtain resonance around $f_{2.45}$, the horizontal length L'_L is chosen such that the total length $H_L+L'_L$ is close to one-quarter wavelength at $f_{2.45}:L'_L=27.5 \mathrm{\ mm}\ (H_L+L'_L=32 \mathrm{\ mm}=0.261 \lambda_{2.45})$. Resonance at $f_{2.45}$ is realized by adjusting the location of feed point (distance L_{FD}). The VSWR frequency response for $L_{\mathrm{FD}}=7.5 \mathrm{\ mm}$ is shown by the solid line in Fig. 2.

The second step is performed using the inverted F element shown in inset (II) of Fig. 2. The height H_F is chosen to be smaller than H_L for the inverted L element, described in Section II: $H_F=2.5~\mathrm{mm}=0.0433\lambda_{5.2}$, where $\lambda_{5.2}$ is the wavelength at $5.2~\mathrm{GHz}~(\equiv f_{5.2})$. The feed point is located at the same point as that for the aforementioned inverted L element ($L_{\mathrm{FD}}=7.5~\mathrm{mm}$). Resonance around $f_{5.2}$ is obtained by choosing the horizontal length L_F' such that the H_F+L_F' is close to one-quarter wavelength at $f_{5.2}:L_F'=11~\mathrm{mm}~(H_F+L_F'=13.5~\mathrm{mm}=0.234\lambda_{5.2})$. The VSWR for this structure is shown by the broken line in Fig. 2. Note that the horizontal lengths L_F' (obtained in the second step) and L_L' (obtained in the first step) are slightly changed to L_F and L_L , respectively, after the fine-tuning in the fifth step.

The third step is to compound the inverted L and F elements determined in the first and second steps, as shown in inset (III) of Fig. 2. The white dots in Fig. 2 show the VSWR for this structure. It is observed that the VSWR at $f_{2.45}$ remains almost unchanged; however the VSWR at $f_{5.2}$ deteriorates due to mutual

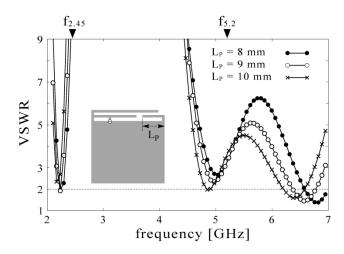


Fig. 3. Effects of the length of a parasitic L element, L_P , on the VSWR, where the structural parameters $(H_L, L_L') = (4.5 \text{ mm}, 27.5 \text{ mm}), (H_F, L_F') = (2.5 \text{ mm}, 11 \text{ mm})$, and $L_{\rm FD} = 7.5 \text{ mm}$ are used. The ground plate size is $L_x \times L_y = 30 \text{ mm} \times 25.5 \text{ mm}$.

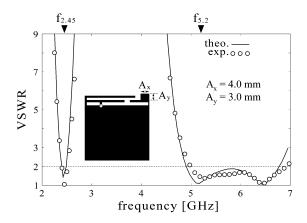


Fig. 4. VSWR for an inverted FL antenna. The structural parameters are $(H_L, L_L) = (4.5 \text{ mm}, \ 24.5 \text{ mm}), (H_F, L_F) = (2.5 \text{ mm}, \ 10.5 \text{ mm}),$ $L_{\rm FD} = 7.5 \text{ mm}, (H_P, L_P) = (2.5 \text{ mm}, \ 9.0 \text{ mm}), (A_x, A_y) = (4.0 \text{ mm}, \ 3.0 \text{ mm}), \text{ and } (L_x \times L_y) = (30 \text{ mm} \times 25.5 \text{ mm}).$

effects between the inverted L and F elements. This is overcome in the following fourth and fifth steps.

In the fourth step, a parasitic L element is added to the structure discussed in the third step, as shown in Fig. 1(a). The height of the parasitic L element is chosen to be equal to that of the inverted F element, as described in Section II: $H_P = H_F =$ 2.5 mm. Fig. 3 shows the VSWR as a function of frequency for three values of the horizontal length of the parasitic L element, L_P , where the structural parameters for the inverted L and F elements are held at the values used in the third step: $(H_L, L'_L) =$ $(4.5 \text{ mm}, 27.5 \text{ mm}), (H_F, L_F') = (2.5 \text{ mm}, 11 \text{ mm}), \text{ and}$ $L_{\rm FD} = 7.5 \ \mathrm{mm}$. It is found that the parasitic L element generates resonances between 6 and 7 GHz. Note that the total length of the parasitic L, $H_P + L_P$, is close to one-quarter wavelength at the frequency where the minimum VSWR for each L_P appears: $H_P + L_P = 0.238 \lambda_{6.8}$ at 6.8 GHz for $L_P = 8$ mm, $H_P + L_P = 0.253\lambda_{6.6}$ at 6.6 GHz for $L_P = 9$ mm, and $H_P + L_P = 0.267 \lambda_{6.4}$ at 6.4 GHz for $L_P = 10$ mm, where λ_f is the wavelength at frequency f.

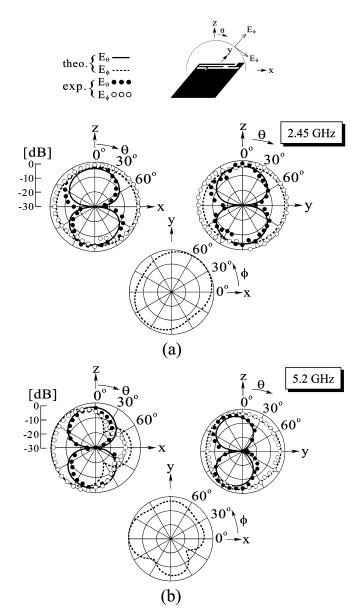


Fig. 5. Radiation patterns of an inverted FL antenna. (a) At 2.45 GHz. (b) At 5.2 GHz. The structural parameters are $(H_L, L_L) = (4.5 \text{ mm}, 24.5 \text{ mm}), (H_F, L_F) = (2.5 \text{ mm}, 10.5 \text{ mm}), L_{\rm FD} = 7.5 \text{ mm}, (H_P, L_P) = (2.5 \text{ mm}, 9.0 \text{ mm}), (A_x, A_y) = (4.0 \text{ mm}, 3.0 \text{ mm}), \text{ and } (L_x \times L_y) = (30 \text{ mm} \times 25.5 \text{ mm}).$

At this point there are two issues: 1) the VSWR curve is slightly shifted downward with respect to frequencies $f_{2,45}$ and $f_{5,2}$; and 2) the VSWR around $f_{5,2}$ is still larger than 2. These issues are solved by the following structural modifications: 1) reduction of the original horizontal strip line lengths L_L' and L_F' , and 2) widening of the strip width of the parasitic L element. Note that the widening of the strip width is realized by making a protrusion on the parasitic L element, where part of the strip line is widened to $w + A_y$ over length A_x , as shown in Fig. 1(b).

The fifth step is to perform the aforementioned structural modifications for dual-frequency operation at 2.45 and 5.2 GHz. Using trial and error, the structural parameters are determined to be $(L_L, L_F, L_P) = (24.5 \text{ mm}, 10.5 \text{ mm}, 9.0 \text{ mm}),$

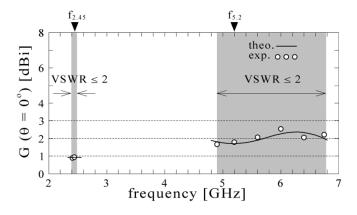


Fig. 6. Gain in the z-direction of an inverted FL antenna. The structural parameters are $(H_L, L_L) = (4.5 \text{ mm}, 24.5 \text{ mm}), (H_F, L_F) = (2.5 \text{ mm}, 10.5 \text{ mm}), L_{\rm FD} = 7.5 \text{ mm}, (H_P, L_P) = (2.5 \text{ mm}, 9.0 \text{ mm}), (A_x, A_y) = (4.0 \text{ mm}, 3.0 \text{ mm}), \text{and } (L_x \times L_y) = (30 \text{ mm} \times 25.5 \text{ mm}).$

 $(A_x,A_y)=(4.0 \text{ mm}, 3.0 \text{ mm})$, and $L_{\rm FD}=7.5 \text{ mm}$. Note that the horizontal lengths L_L and L_F are slightly smaller than the original lengths L_L' and L_F' in Fig. 1(a), respectively. Also note that the largest antenna height (H_P+A_y) is very small with respect to the wavelength: 5.5 mm=0.045 wavelength at 2.45 GHz. Fig. 4 shows the frequency response of the VSWR for the InvFLA defined with these final values for the structural parameters. This figure clearly indicates dual-frequency operation at $f_{2.45}$ and $f_{5.2}$. The frequency bandwidth for a VSWR = 2 criterion is 4.1% for the $f_{2.45}$ band and 31.8% for the $f_{5.2}$ band. The results are confirmed by the experimental results (white dots).

Fig. 5 shows the radiation patterns at $f_{2.45}$ and $f_{5.2}$. For confirmation of the FDTDM results, experimental results in the principal planes (x-z and y-z planes) are presented. Additionally, only the FDTDM results of the radiation patterns in the x-y plane at $f_{2.45}$ and $f_{5.2}$ are presented for completeness. The radiation patterns are useful in understanding the gain characteristic in the z direction $G(\theta=0^\circ)$, which is shown in Fig. 6 together with experimental results, where the shadowed areas in the figure show the VSWR bands. It is found that the gain (with respect to an isotropic source) is approximately 0.9 dBi at $f_{2.45}$ and approximately 1.7 dBi at $f_{5.2}$, with a small gain variation in each VSWR band. These gain values are small due to the fact that the radiation is not highly directive, as seen from the radiation pattern E_{ϕ} .

The difference between the gains at $f_{2.45}$ and $f_{5.2}$ (i.e., the gain in the z-direction at 2.45 GHz is smaller than that at 5.2 GHz) is attributed to the following facts: 1) the radiation pattern E_{ϕ} at 2.45 GHz in each of the x-z and y-z planes is more omnidirectional than that at 5.2 GHz and 2) the radiation pattern E_{θ} at 2.45 GHz in each of the x-z and y-z planes (having a figure-eight pattern) shows a wider half-power beam width than that at 5.2 GHz.

An omnidirectional pattern is desirable for communications between a fixed base station antenna and an antenna installed in a *mobile* device. Note that, if a more omnidirectional E_{ϕ} pattern (in the x-z plane) is required for the InvFLA at 5.2 GHz, this

can be achieved by placing the parasitic L element just under the horizontal strip line of the inverted F [13].

IV. CONCLUSION

An InvFLA, made of a thin conducting film, has a card-type structure, where the radiation element is a compound of inverted L and F elements, which is adjacent to a co-planar ground plate. The design procedure for dual-frequency operation at $f=2.45\,\mathrm{GHz}$ and $5.2\,\mathrm{GHz}$ is described in five steps. In the first step, an inverted L element is designed for operation at $2.45\,\mathrm{GHz}$. In the second step, an inverted F is designed for operation at $2.45\,\mathrm{GHz}$. Based on these designs, a compound of the inverted L and F elements is investigated in the third step. Fine adjustment for dual-frequency operation is performed by introducing a parasitic L element in the fourth step and then modifying the parasitic L element in the fifth step.

It is found that the VSWR frequency bandwidth of the InvFLA is 4.1% around 2.45 GHz and 31.8% around 5.2 GHz. It is also revealed that the E_{ϕ} component of the radiation field from the InvFLA spreads out in a somewhat omnidirectional fashion. Further analysis shows that the gain variation in each VSWR band is small. The gain in the z direction (normal to the antenna plane) is 0.9 dBi at 2.45 GHz and 1.7 dBi at 5.2 GHz.

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REFERENCES

- Y. Guo, M. Y. W. Chia, and Z. N. Chen, "Miniature built-in quad-band antennas for mobile handsets," *IEEE Antennas Wireless Propag. Lett.*, vol. 2, pp. 30–32, 2003.
- [2] M. Ali, G. J. Hayes, H. Hwang, and R. A. Sadler, "Design of multiband internal antenna for third generation mobile phone handsets," *IEEE Trans. Antennas Propag.*, vol. 51, no. 7, pp. 1452–1461, Jul. 2003.
- [3] Y. Guo, I. Ang, and M. Y. W. Chia, "Compact internal multiband antennas for mobile handsets," *IEEE Antennas Wireless Propag. Lett.*, vol. 2, pp. 143–146, 2003.
- [4] M. F. Abedin and M. Ali, "Modifying the ground plane and its effect on planar inverted-F antennas (PIFA's) for mobile phone handsets," *IEEE Antennas Wireless Propag. Lett.*, vol. 2, pp. 226–229, 2003.
- [5] Y. Kwon, J. Moon, and S. Park, "An internal triple-band planar inverted-F antenna," *IEEE Antennas Wireless Propag. Lett.*, vol. 2, pp. 341–344, 2003.
- [6] D. Llorens, P. Otero, and C. C-Penalosa, "Dual-band, single CPW port, planar-slot antenna," *IEEE Trans. Antennas Propag.*, vol. 51, no. 1, pp. 137–139, Jan. 2003.
- [7] S. Yeh, K. Wong, T. Chiou, and S. Fang, "Dual-band planar inverted F antenna for GSM/DCS mobile phones," *IEEE Trans. Antennas Propag.*, vol. 51, no. 5, pp. 1124–1126, May 2003.
- [8] H. Chen, W. Chen, Y. Cheng, and Y. Lin, "Dualband meander monopole antenna," in *Proc. IEEE Antennas and Propagation Soc. Int. Symp.*, vol. 3, Columbus, OH, Jun. 2003, pp. 48–51.
- [9] K. Wong, Compact and Broadband Microstrip Antennas. New York: Wiley, 2002.
- [10] A. Taflove, Computational Electrodynamics: The Finite-Difference Time Domain Method. Norwood, MA: Artech House, 1995.
- [11] Z. P. Liao, H. L. Wong, B. P. Yang, and Y. F. Yuan, "A transmitting boundary for transient wave analysis," *Science Sinica, Series A*, vol. 27, no. 10, pp. 1063–1076, 1984.
- [12] C. A. Balanis, Antenna Theory: Analysis and Design, 2nd ed: Wiley, 1982, pp. 575–594.

[13] H. Nakano, K. Morishita, Y. Sato, H. Mimaki, and J. Yamauchi. A cardtype inverted LFL antenna for dual-frequency operation. presented at Proc. IEEE-ACES Int. Conf. Wireless Communications and Applied Computational Electromagnetics. [CD-ROM] s27p03i



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